

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named		
Inventor :	Benjamin Y.H. Liu	
Appln. No.:	10/769,011	Group Art Unit: 1792
Filed :	January 30, 2004	
For :	HIGH-PERFORMANCE AND MULTI- LIQUID-PRECURSOR VAPORIZATION IN SEMICONDUCTOR THIN FILM DEPOSITION	Examiner: Bueker, Richard R.
Docket No.:	M419.12-0043	

AMENDMENT

**FILED ELECTRONICALLY
FEBRUARY 23, 2009**

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Amendment is in response to the Official Action of January 29, 2009.

Please amend the above-identified application as follows.